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Bio-sorbable, liquid electrolyte gated thin-film transistor based on a solution processed zinc oxide layer

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- Among the metal oxide semiconductors, ZnO has been widely investigated ¹⁰as channel material in thin film transistors (TFTs) due to its excellent electrical properties, optical transparency and simple fabrication via solution processed techniques. Herein, we report a solution processable ZnO based thin-film transistor gated through a liquid electrolyte with an ionic strength comparable to that of a physiological fluid. The surface 15 morphology and chemical composition of the ZnO films upon exposure to water and phosphate buffer solution (PBS), are discussed in terms of operation stability and electrical performance of the ZnO TFT devices. Improved device characteristics upon exposure to PBS are associated with the enhancement of the oxygen vacancies in ZnO lattice due to Na+ doping.
- ²⁰Moreover, dissolution kinetics of ZnO thin film in liquid electrolyte opens to possible applicability of these devices as active element in "transient" implantable systems.

1 Introduction

Over the years, semiconductor oxides based thin-film transistors have attracted a ²⁵great deal of attention due to their high charge-carrier mobility, transparency and excellent chemical and mechanical stability [1,2,3]. Indeed, transparent electronics have gained attention during the last few years and are today established as one of the most promising technologies for the next generation of flat panel displays due to the excellent electronic performance of many wide band-gap semiconductor oxides.

- ³⁰In particular, zinc oxide (ZnO) is an interesting and promising material as it holds a favorable combination of properties, including excellent transparency in the visible range, high electronic properties, even when processed from solution, and strong piezoelectric properties [4,5]. Last but not least, ZnO is biocompatible [6,7] and biodegradable while Zinc is among the most abundant element in the earth's crust.
- ³⁵All these make ZnO a key functional material with versatile properties for important applications in sensing, catalysis, optical emission, piezoelectric transduction, and actuation [8]. It would be also suitable as active layer in electronic devices that can be integrated in a living organism, even in the human body.

 High-performance metal oxide TFTs are typically manufactured by vacuum-⁴⁰processing methods, such as radio frequency magnetron sputtering and pulsed laser deposition, which pose some limitations in mass production for the realization of low-cost optoelectronic applications. Solution processable oxide semiconductors

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represent indeed a fast emerging technology that holds promise in the area of TFT applications. Recently significant research effort has been devoted to developing novel material and methodologies to improve electronic transport figures of merit, as well as to actuate processing at low-temperature to ensure compatibility with plastic

- ⁵or even biodegradable paper or silk substrates [3,9,10]. For this reason, a large research effort is dedicated to the development of solution-processing methods for the fabrication of oxide TFTs, including ZnO ones [11,12,13,14]. Studies in this direction involve ultraviolet photochemical activation of sol–gel precursors [15,16], sol-gel on chip [17], along with a number of colloidal nanoparticle-based approaches
- 10 [18,19]. The use of preforming colloidal metal oxide nanocrystals and nanoparticles (NPs), offers advantages but the high melting temperatures along with the presence of highly insulating carbon-based surfactants lead to transistors with modest performance level even at relatively high sintering temperatures [18]. Recent advances in sol-gel based methods have, on the other hand, enabled the development
- 15 of oxide based TFTs with electron mobility as high as 11 cm²/Vs at 250 °C [17]. A very interesting approach has been also proposed that sees high-performance ZnO transistors processed via an aqueous carbon-free metal oxide precursor route at temperatures between 80–180 °C [20].
- Lately, the concept of gating TFTs with a ionic conducting electrolyte [21,22], ²⁰rather than with an insulating dielectric, has been put forward as it allows for low voltage operation directly through a droplet of pure water [21], but also by means of a high ionic strength fluid in contact with a TFT channel, this making such devices very promising also for bio-organic electronic applications [23]. In electrolyte gated TFTs (EG-TFT), the electrolyte serves as dielectric being positioned, as customary,
- ²⁵between the gate electrode and the semiconductor active channel material. In a typical n-type EG-TFT device, when a positive gate bias is applied, the anions migrate towards the gate-electrolyte interface and the cations migrate towards the semiconductor-electrolyte interface, leaving a charge-neutral electrolyte in between them. This ions migration leads to a net charge accumulation at the gate-electrolyte
- ³⁰(negative charges) and semiconductor-electrolyte (positive charges) interfaces generating, at the steady state, two electrical double layers (EDLs) one at each interface, with all the applied voltage that drops across the EDLs. The total capacitance of the electrolyte gating layer, determined by the capacitance of the two EDLs connected in series, is dominated by the smaller of the two single EDLs. The
- 35 value of capacitance is typically on the order of 10 μ F/cm², thus making it possible to induce a very large charge carrier concentration $({\sim}10^{15} \text{ cm}^{-2})$ in the transistor channel at relatively low applied gate voltages (<3V) [21]. In addition, as the static capacitance of the electrolyte is virtually independent from the thickness of the electrolyte layer, even a thick layer will allow to attain low-voltage operation, but ⁴⁰also the device figures of merit are independent from thickness inhomogeneities.

 This approach has been used also to gate ZnO based TFTs, mostly through solid ionic polymers and gels, as well as ionic liquids. Interestingly, solid electrolyte gated ZnO TFTs have been used to fabricate an inverter circuit by printing on a plastic substrate [24]. In this case, high-mobility, low-voltage ZnO TFTs on a kapton

⁴⁵substrate were fabricated by aerosol jet printing, this being a versatile method for patterning a wide range of electronically functional liquid inks [25]. To achieve lowvoltage operation a printable high-capacitance $(3.80 \mu F/cm^2)$ ion-gel solid electrolyte was used, as already previously proposed [26]. Such gating materials allow to operate the device below 2V in a nitrogen environment, reaching field

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effect mobility and threshold voltage of $1.67 \text{ cm}^2/\text{Vs}$ and 0.97 V, respectively. A similar contribution has been published regarding an amorphous ZnO channel gated trough an ionic liquid tape [27]. Other few contributions concerning ZnO based TFT gated through solid electrolytes such as ionic liquids [28,29] or composite solid ⁵polymer, can be found. In the latter case a ZnO single nanowire is used as the active element of the channel, the field-effect mobility and the threshold voltage of a typical ZnO single-nanowire transistor being $62 \text{ cm}^2/\text{Vs}$ and 0.93 V, respectively [30]. Interestingly, the electrochemical gating approach is shown not to limit the switching speed of the device, as the frequency in the range of 100 kHz is already ¹⁰achievable with an in-plane transistor geometry. Moreover, unlike the ionic liquids, the composite solid polymer electrolyte studied in this work is found to be stable under ambient conditions and the transistors have shown no noticeable degradation after an exposure of 3–4 weeks in air. More recently an innovative contribution proposed by the Grell's group reported on a ZnO electron transporting thin-film ¹⁵transistors directly gated through a drop of pure water [31]. To minimize the impact of water on the stability of the thermally converted precursor route ZnO, the surface

- was modified by an hexamethyldisilazene hydrophobic layer. Assuming a capacitance per unit area (C_i) of 3 μ F/cm² measured on a water-gate polythiophenes TFT [21] an electron mobility as high as 8.8 cm^2/Vs was found in this case, similar 20 to the 5.25 cm²/Vs report for a "dry" gated precursor-route ZnO TFT [32]. On the
- other hand much worse figures of merit are found by using a small gate area. This can be rationalized considering that a gate capacitance, comparatively higher that the ratio between the channel and gate contact area, should be in place to assure the same level of performances [33].
- ²⁵As already outlined, one of the relevant aspects of ZnO structures is their biocompatibility. ZnO nanoparticles are indeed believed to be nontoxic, bio-safe and biocompatible as proven by their use for many every-day life applications, such as drug carriers and cosmetics. For instance a study on the biocompatibility of ZnO nanowires at the cellular level, have shown that they are completely biocompatible,
- ³⁰bio-safe and are ranked as reliable and trustworthy for applications in biomedicine and engineering [7]. Moreover, biodegradability and biocompatibility of ZnO nanowires or nano-belts, which is crucial for the application of ZnO nanostructure for biosensing, has been also assessed [34]. A novel and extremely interesting approach foresees the use of water sorbable devices and circuits [35,36,37] to be
- ³⁵used as implantable "transient" opto-electronic systems. Not only ZnO has been shown to dissolve in water on in an electrolyte [34], but ZnO devices have been even fabricated on silk or paper substrates that quickly vanishes by simple dissolution. Each composing material disappears due to hydrolysis at different rates and the time frames for dissolution can be programmed not only by encapsulation
- ⁴⁰and packaging methods, but also by choices of dimensions, thicknesses and configurations in the materials for the device structures. This "transient" device and circuits could be used to regulate body functions, record biometrics or dispense medicines

 In this paper, we are proposing solution processed ZnO based TFTs gated through ⁴⁵a phosphate-buffered saline (PBS) solution 10 mM (pH 7.4) put in direct contact with the ZnO surface. The ionic strength of the PBS electrolyte used is 162 mM while that of the human blood serum is 160 mM. As previously outlined, while a few reports are available on water gated ZnO TFT [31], to the best of our knowledge, this is the first time that a liquid electrolyte with an ionic strength comparable to that

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of a biological fluid, is used to gate a ZnO TFT. A full morphological and chemical surface characterization is reported. In addition, the study of the optical and electronic properties of such devices is provided along with the dissolution kinetics, showing how this technology can be useful for "transient" implantable devices.

⁵**2. Experimental**

2.1 Preparation of ZnO Precursor Solution

The ZnO precursor solution (0.1M) was prepared by dissolving zinc acetate dihydrate $Zn(CH_3COO)_{2} \cdot 2H_2O$ in ethanol. The solution was stirred for 7h and at 80 ^oC, until a transparent, homogenous solution was obtained. The as-prepared 10 precursor solution was deposited via spin-coating onto thermally oxidized silicon wafers $(Si/SiO₂)$ for device fabrication.

2.2 Device Fabrication

Prior to spin-coating, the $Si/SiO₂$ substrate was photolithographically patterned with source (S) and drain (D) electrodes (Au/Ti = 50 nm/5 nm). The channel length and ¹⁵width were, unless differently stated, 10 µm and 10000 µm respectively. The substrates were cleaned with a Piranha solution (3:1 mixture of sulfuric acid and hydrogen peroxide) and thoroughly rinsed with solvents of increased polarity (acetone, isopropyl alcohol and deionized water). The precursor solution was deposited on the S-D patterned substrate by spin coating with a Laurell

- ²⁰Technologies WS-650MZ-23NPP/LITE instrument. The thin-film deposition was performed by dispensing a 70 μ l drop of precursor solution on the SiO₂ surface and subsequent spinning at 2000 RPM for 50 seconds. The desired film thickness was obtained by repeating for 3 times the deposition procedure. Before each further coating, the films were pre-heated at $150 \degree C$ to remove the organic residue. The
- 25 resulting deposit was calcined at 450 $^{\circ}$ C for five hours on a hot plate. All the chemicals and solvents (high quality grade) were purchased by Sigma-Aldrich and used without any further treatment.

2.3 ZnO thin-film characterization

A thermogravimetric analyzer (Perkin Elmer Pyris 6 TGA) was used to study the 30 thermal behavior of $Zn(CH_3COO)_2 \cdot 2H_2O$ in the temperature range from 30 to 500 $\rm{^{\circ}C}$ with a heating rate of 10 $\rm{^{\circ}C/min}$ in a 40 ml/min dinitrogen flow.

 The topographical and cross-sectional view micrographs of the films were acquired by a scanning electron microscope (Carl Zeiss SEM system, mod. Sigma). The thickness of the film was evaluated from the cross-sectional SEM image.

- ³⁵Surface chemical composition of the ZnO films, before and after the exposure to water and PBS solutions, was realized with an X-ray photoelectron Thermo VG Theta Probe spectrometer equipped with a micro-spot monochromatized Al K α source. Both survey scans and high resolution spectra were acquired in fixed analyzer transmission mode with pass energy of 150 and 100 eV, respectively. The
- ⁴⁰X-ray Photoelectron Spectroscopic (XPS) data were processed with the *Avantage* software [38]. The aliphatic C1s component fixed at BE values of 284.8 ± 0.1 eV is referenced for calibration of the binding energy (BE) scale. The surface chemical speciation (in $At\%)$ of each sample is determined by evaluating the integrated peak areas of the principle photoelectron peaks and the respective sensitivity factor [39].

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2.4 TFT electrical characterization.

The transistor current-voltage (*I-V*) characteristics were measured, through a pure deionized water or PBS solution gating, with an Agilent 4155C and Keithley 4200- SCS Semiconductor Parameter Analyzers. Worth to mention is that PBS solution 10 5 mM (pH 7.4) contains a great deal of Na⁺ ions. In figure 1 a scheme of the device structure is reported.

The output characteristics $(I_{DS}$ vs. V_{DS}) were measured ranging the source-drain voltage (V_{DS}) between 0 and 0.5 V, while the gate bias (V_G) was kept constant for each curve and varied from one curve to the other in step of 0.1V. The transfer 10 characteristics (I_{DS} vs. V_G) were recorded keeping the drain voltage (V_D) constant at 0.5 V. Each current trace was measured in the forward and reverse mode to evidence the occurrence of any hysteresis. The transistor electrical parameters, namely the field-effect mobility (μ) , the threshold voltage (V_T) as well as the *on/off* current ratio (I_{on}/I_{off}) , were extracted from the characteristic curves in the saturation regime

3. Results and Discussion

3.1 Thermogravimetric Analysis

- A thermogravimetric analysis (TGA) was performed in order to study the thermal 20 decomposition of zinc acetate dihydrate $(\text{Zn}(\text{CH}_3\text{COO})_2 \bullet 2\text{H}_2\text{O})$ and the formation of a stable ZnO phase. The thermogram trace and its first derivative at a temperature ranging from 30 to 500 $^{\circ}$ C are shown in figure 2 and in the inset, respectively. The first thermal event is observed at 102.6^oC and is completed at 119^oC with a ~16.7 % weight loss. This weight loss can be attributed to the thermal dehydration of zinc
- ²⁵acetate dehydrate and more specifically to the loss of the two water molecules. By further increasing the temperature, the decomposition of anhydrous $\text{Zn}(\text{CH}_3\text{COO})_2$ into ZnO occurs at ~316.9°C, and is completed at ~353°C. Beyond this temperature, and up to 500°C, the formation of stable ZnO crystal takes place, and no further weight loss is observed. Based on these results, we decided to carry out the 30 calcination at 450°C, since a stable ZnO phase is obtained. These observations are
- also in good agreement with previously reported results [32,41].

3.2 Optical Properties

The optical transparency of the ZnO thin film was evaluated on film deposited on a quartz substrate whose UV-VIS transmittance spectrum is shown in figure 3a. The ³⁵optical absorption peak was observed at a wavelength of *ca.* 354 nm which falls in the ultraviolet region of the spectrum, proving the ZnO transparency in the visible

region. Considering that ZnO holds a direct band gap transition, the energy gap (E_{g}) was obtained by using the Bardeen equation [42]:

$$
\alpha h v = B (h v - E_g)^{1/2} \tag{1}
$$

40 where α is the absorption coefficient and B is a constant [43]. The extrapolation from the linear portion to $ahv = 0$ (figure 3b) results in an E_g ~ 3.29 eV

3.3 X-Ray Photoelectron Spectroscopy Surface characterization

X-ray photoelectron spectroscopy (XPS) characterization of ZnO film was carried

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¹⁵ following an assessed procedure [40]. All measurements were carried out in ambient air (relative humidity ca. 36%, T=25 °C).

out to investigate how the water or PBS solutions influence the surface chemistry. Since the Zinc binding energy is not affected by chemical speciation, therefore O1s spectral region was studied for ZnO film, before and after exposure to either water or PBS solution, and the results are shown in figure 4. Deconvolution of O1s signals

- ⁵showed always the presence of four component peaks centered at 530.1±0.2 eV, 531.1±0.2 eV, 532.2±0.2 eV, and 533.3±0.2 eV, labeled as A, B, C, and D in the figure 4. Peak A was assigned to oxygen in the ZnO lattice; peak B was attributed to oxygen in oxygen-deficient region in ZnO matrix [44,45]; peak C was associated to oxygen adsorbed on the surface of ZnO film; lastly peak D was assumed to come
- 10 from SiO₂ as substrate. Interestingly, the four peak components are positioned at the same binding energy in all the samples, and the O1s XP spectrum before and after water exposure is exactly the same. When the film is exposed to the PBS solution a different O1s shape is observed: in particular the intensity ratio B/A is increased, indicating an increase in the oxygen vacancies [44,45]

¹⁵**3.4 Scanning Electron Microscopy**

The surface morphology and the thickness of the ZnO thin film was evaluated by means of a scanning electron microscopy (SEM) analysis. The SEM images, showing the morphological and cross-sectional views of a ZnO thin-film deposited on the $Si/SiO₂$, are shown in figure 5a and figure 5b, respectively. The film clearly

- ²⁰exhibits a granular morphology and has a densely packed structure [46]. The film thickness was evaluated from the cross-sectional image as 46 ± 5 nm. In figure 5c and figure 5d the SEM images of ZnO films exposed to water and PBS solutions, respectively, for 14 h under steering conditions, are reported. ImageJ Software [47] was used to evaluate the effect of the different electrolytes on the size of the grains.
- 25 The average grain size, as calculated, was found to be $29±9$ nm, $28±6$ nm and $26±7$ nm for bare ZnO and for the films exposed to water and PBS, respectively. The analysis of the images shows that an overall similar granular morphology is retained after exposure to the two electrolytes, although a slight decrease in the average grain-size can be seen for the PBS exposed film.

³⁰**3.5 Electrolyte gated TFT Characteristics**

Figure 6 shows the output and transfer characteristics of the pure deionized water and PBS (10 mM, $pH = 7.4$) gated ZnO based thin-film transistors. In figure 6a and 6c the I_{DS} current exhibits well shaped linear and saturation regions, as the V_{DS} bias is swept, showing also good modulation with the gate bias V_G . The hysteresis shown

³⁵by the water gated device is visibly larger. The transfer characteristics in both cases (figure 6b and 6d) were measured at three different integration times and also in this case the dependence of the integration time is larger for the water gated compared to the PBS one. Both these evidences concur to show that a more stable electronic behavior is shown by the device operated through the PBS solution. This is an ⁴⁰important aspect that will be addressed later on the text. In the saturation regime the curves follow the well-known analytical expression that is:

$$
I_{DS} = \frac{w}{2L} \mu * C_i (V_G - V_T)^2
$$
 (2)

The TFT field-effect mobility multiplied by the capacitance per unit area, μ^*C_i , 45 and the threshold voltage (V_T) were derived from the slope (B) and intercept (A) of

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the linear $\sqrt{I_{DS}}$ vs. V_G plot, according to equation (4) and (5) reported below:

$$
\mu * C_i = \frac{B^2 2L}{W}
$$
 (3)

$$
V_T = -\frac{A}{B}
$$
 (4)

 The device figures of merit averaged over 3-4 different devices with the relevant ⁵uncertainties (one standard deviation) are reported in Table 1. Table 1 offers also a comparison with the literature data concerning ZnO TFTs gated trough different solid electrolytes. The comparison is made also with the sole report already published on water gated ZnO TFT. To allow for a fair comparison, rather than the mobility data, the μ^*C_i figure of merit is proposed. This is necessary as fully reliable 10 values for the capacitance of liquid or solid electrolytes are not always available.

 The measured electrical characteristics obtained from the proposed ZnO devices, summarized in Table 1, present a descent field effect behavior. The devices operate at voltages lower than 0.5V, which is attributed to the electrolyte gating layer. The threshold voltage (V_{th}) is ~0.15V and it is among the lowest reported. The I_{on}/I_{off} 15 ratio is 10^2 for water and 10^3 for PBS. These values are comparable to that of liquid gated ZnO TFTs [31, 29]. Moreover, the *on/off* current ratio can be improved by patterning the active channel area. The value of μ^*C i with PBS as electrolyte is 1.4×10^{-6} F/Vs at the saturation regime, which is similar to that of devices fabricated using solid electrolyte as the dielectric layer [24].

- ²⁰Interesting is to comment that the I-V curves of the ZnO thin-film exposed to PBS, that is reach in Na⁺ ions, exhibit improved electrical characteristics in terms of hysteresis, I_{on}/I_{off} current ratio and μ *Ci. More specifically, the hysteresis gap observed in the case of water gated ZnO TFT device reveals the occurrence of charge trapping in the reverse voltage sweep in both the output and transfer
- ²⁵characteristics (see figure 6a and b). In all cases, the reverse sweep current curve is lower than the forward sweep curve. Furthermore, by reducing the integration time of the gate voltage sweep, an increase in the hysteresis gap is evident, along with a decrease in the maximum on-current (figure 6b). Probably, for a longer duration of the biasing, more charges have time to reach lower energy states and occupy trap
- ³⁰sites. On the other hand, when the device is gated with the PBS electrolyte solution, almost hysteresis free I-V curves are obtained (see figure 6c and d). In addition, higher on current is achieved meaning that a larger amount of free carriers is accumulated in the semiconductor/electrolyte interface.
- It has been recently demonstrated, that Na⁺ ions can act as dopants in ZnO, ³⁵tending to occupy interstitial sites rather than substitutional ones, therefore acting as donors and not as acceptors [48]. It has been also suggested that the presence of sodium ions can cause a lack of stoichiometry in the ZnO lattice and therefore induce oxygen vacancies [45]. This is confirmed by the XPS analysis reported in figure 4, where an increase in the oxygen vacancies is observed in the case of ZnO
- 40 films exposed to the PBS solution. Indeed, the exposure to $Na⁺$ present in the PBS solution seems to alter the oxide semiconductor lattice on the surface, giving rise to oxygen vacancies. Although, oxygen vacancies can produce potential wells that can act as trapping sites and hinder the free carrier (electrons) movement (as in the case of water) [44], the excess of free electrons originating from interstitial doping due to
- 45 Na⁺ is such that can fill the existing trap sites and moreover induce more charges in the semiconductor's channel (as in the case of PBS) [45].

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3.6 ZnO film dissolution kinetics in water and PBS

The kinetics of ZnO dissolution in aqueous environments, were determined by anodic stripping voltammetry (ASV). The $Si/SiO₂$ substrates, coated by a ZnO film according to the procedure used in the TFT fabrication, where placed in vials ⁵containing 3 ml of water or PBS and left under mild steering on a roller mixer for different time lapses. References (blanks) slides were left out of the liquids. The amount of residual ZnO at a given time lapse, after the immersion, is defined as weight percentage of ZnO with respect to the blank. At a given time the slide was removed from the liquid and the coating was dissolved using a wet digestion

- ¹⁰procedure with nitric−perchloric acids. The solutions obtained after digestion were diluted with deionized water, adjusted to pH in the 5.0−5.5 range with acetate buffer and dehydrated with a stream of nitrogen for 100 s. The amount of zinc cations dissolved in solution was measured with a differential pulse ASV electrochemical procedure using a three-electrode cell equipped with a hanging mercury drop
- 15 electrode (HMDE) used as the working electrode, an Ag/AgCl with saturated 3 M KCl reference electrode, and a platinum wire counter electrode. Electrochemical deposition was performed at −0.8 V for 45 s under stirring. After this time the stirrer was switched off, and the oxidation curves were recorded in the potential range from −1.15 to −0.75 V (sweep rate of 0.06 V s−1). Zinc was quantified by addition of a $_{20}$ Zn²⁺ standard solution in the cell.

 In figure 7 the data are reported for the ZnO dissolution in water over a time of 25 h. The zinc actually remaining on the sample after the exposure to water decreases to 46% after 16 h in water, while it decreases down to 25% after exposure to PBS. On the other hand, a stable device operation will be proven on the half an hour time

- ²⁵lapse later in this manuscript, however the limiting factor is the gating droplet evaporation not the ZnO film degrading. The actual time of device stable operation is in fact much longer being to compare the "transient time" of these devices with literature data [37].
- ZnO appears to react differently under water and PBS solution. The different ³⁰dissolution processes can be also accounted for by evaluating the degree of hydrophobicity of the ZnO surface after exposure to the two electrolytes. Improved wettability has been ascribed to enhance dissolution of solid dispersions. Static contact angle evaluation was performed by using a CAM 200 goniometer (KSV Instruments Ltd, Finland) and placing a 2 µL droplet of water or PBS 10 mM on the
- 35 ZnO film surface at room ambient conditions (T = 25 °C). The measurement was repeated three times by placing the drop on different areas of the same sample measuring average contact angles of 57 ± 2 for water and 39 ± 6 for PBS, this being more hydrophobic. Interestingly, such a difference cannot be ascribed to differences in the surface tension in the liquid phase because water and PBS have the same
- 40 value (71.5±0.2 mJ⋅m⁻²) measured using a Du Noüy ring tensiometer (Krüss Gmbh, Germany). The difference in the contact angle, therefore, must be ascribed to differences in the solid phase in contact with the liquid droplet and this occurrence strongly suggest a doping of the ZnO by ions (presumably Na⁺) present in PBS and not in pure water.

⁴⁵**3.7 Operational stability of water gated ZnO TFTs**

Another important aspect to be addressed is the operational stability of the proposed ZnO TFT devices. Current instability in thin film transistors under gate voltage biasing is crucial for the practical application of such devices. For this purpose,

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double transfer characteristic curves were recorded repeatedly, every 5min, from the moment the device was gated with a water drop until 40 min after. It is important to mention, that the device's channel length and width, used for these measurements, is 2 µm and 60 mm, respectively. As it is shown in Figure 8a, the device exhibits a ⁵stable performance for 25 min. A current decay is observed after half an hour and it can be attributed to possible evaporation of the electrolyte solution. This is further

- confirmed by the corresponding values of the V_T and μ^*C_i as a function of time reported in figure 8b, where a clear decrease of the µ*Ci value is in fact observed after 20 min. Pulsed transient measurements⁴⁹ have been carried out to examine the ¹⁰dynamic bias stress current instability as well. We used a rectangular wave as
- dynamic pulse. The pulse-on time was 10ms (V_G = 0.5V) while the pulse-off time was 1s ($V_G=0V$) at constant $V_{DS}= 0.5V$. As it is illustrated in figure 8c, stable output current signal in time is observed for approximately more than 10min. As previously mentioned, the limiting factors to record further the drain current as a function of ¹⁵time are the evaporation of the water droplet and not the degradation of the device.

4. Conclusions

In this study, we have operated an electrolyte gated ZnO TFT, using a liquid electrolyte with ionic strength similar to that of physiological fluids. The ZnO precursor solution was prepared by sol-gel method while aalcination was realized at

- $_{20}$ 450 °C. Low-voltage operation (0.5 V) was achieved with the electrical figures of merit being in good agreement with those previous reported for an electrolyte gated ZnO TFTs. The carrier density induced in the case of PBS electrolyte, was proven to fill possible trap sites, leading to on-current values higher than water gated ones. The I-V curves were also hysteresis free exhibiting also a slight shift of V_T to lower
- 25 voltage value. The enhanced performance of the PBS gating was attributed to interstitial doping of the ZnO matrix by Na⁺ ions present in PBS and not in pure water. The proposed mechanism was further confirmed by XPS analysis of the surface chemical composition of ZnO films exposed to water and PBS. Finally, the dissolution profile of ZnO in water and PBS along with the operational stability of ³⁰the devices was studied, showing that this technology can be useful for "transient"
	- implantable devices.

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Figures and Table captions

Fig. 1: Electrolyte gated TFT device structure

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Fig. 2 TG thermogram (30–500 °C) of Zn(CH3COO)₂ \bullet 2H₂O. Inset: First derivative of the TG thermogram

Fig.3 (a) Optical transmittance spectra of ZnO thin film deposited on a quartz substrate (b) Optical band gap of ZnO thin film

Fig. 4. O1s XP spectra of the (a) ZnO film (b) ZnO sample kept in water and (c) PBS, for 30min

Fig. 5 Topographical scanning electron microscope view of (A) ZnO thin film, (B) cross-sectional view of ZnO thin film, (C) ZnO sample kept in water and (D) PBS, for 14 hours under steering.

Fig. 6. Current-voltage (I-V) characteristics of electrolyte gated ZnO TFT: Output (I_{DS} vs. V_{DS}) for (a) water, (c) PBS. Transfer (I_{DS} vs. V_G) for (b) water, (d) PBS at V_{DS} =-0.5V.

Fig. 7 Dissolution profile of ZnO film in water

Fig. 8 (a) I-V transfer characteristics of water gated ZnO TFT measured repeatedly for 40 min, and (b) the relevant V_T , μ^* Ci values, (c) pulsed transient current measurement of water gated ZnO TFT device.

Table 1 Comparison of the electrical figures of merit of solution processed electrolyte gated ZnO TFTs

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Table 1 Comparison of the electrical figures of merit of solution processed electrolyte gated ZnO TFTs

82x38mm (300 x 300 DPI)

64x50mm (300 x 300 DPI)

130x99mm (300 x 300 DPI)

108x143mm (300 x 300 DPI)

170x128mm (300 x 300 DPI)

133x103mm (300 x 300 DPI)

63x48mm (600 x 600 DPI)

